Supporting Information for “Cathodic deposition of interlaced nanosheet-like cobalt sulfide films for high-performance supercapacitors”

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Figure S1 X-ray energy dispersive spectroscopy of the thin film deposited on Ni foam.

Figure S2 FESEM images of the interlaced nanosheet-like CoS electrode after 1000 consecutive charge-discharge cycles at 8 A g⁻¹. (a) 10000 X and (b) 50000 X.